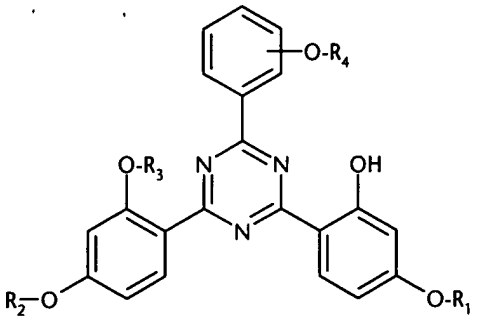
1. (original): A UV absorber composition comprising

(a) from 1 to 99 % by weight of a hydroxyphenyltriazine compound of formula

(1)  wherein

R_1, R_2 and R_3 are each independently of the others C_1-C_{18}alkyl; C_2-C_{10}alkenyl; or phenyl-C_1-C_4alkyl;

R_4 is hydrogen; or C_1-C_5alkyl; and

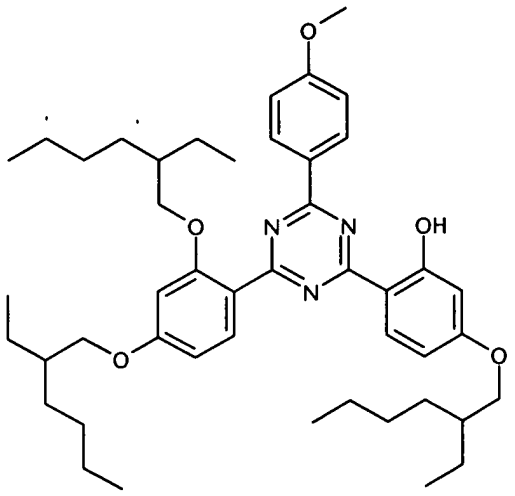
(b) from 99 to 1 % by weight of a further UV absorber selected from the group of (b_1) hydroxyphenyltriazines that are different from component (a), (b_2) benzotriazoles, (b_3) dibenzoylmethane derivatives and (b_4) camphor derivatives.

2. (original): A UV absorber composition according to claim 1, which comprises
from 5 to 95 % of component (a) and
from 95 to 5 % of component (b).

3. (currently amended): A UV absorber composition according to ~~either~~ claim 1 ~~or claim 2~~, wherein
R_1, R_2 and R_3 are each independently of the others C_5-C_{12}alkyl.

4. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 3~~ claim 1, wherein
R_1, R_2 and R_3 have the same meaning.

5. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 4~~ claim 1, wherein component (a) corresponds to formula

(2) 

6. (currently amended): A UV absorber composition according to ~~either~~ claim 1 ~~or claim 2~~, wherein, in formula (1),

R_1 and R_2 are C_5-C_{12}alkyl;

R_3 is C_2-C_{12}alkenyl; and

R_4 is hydrogen; or C_1-C_5alkyl.

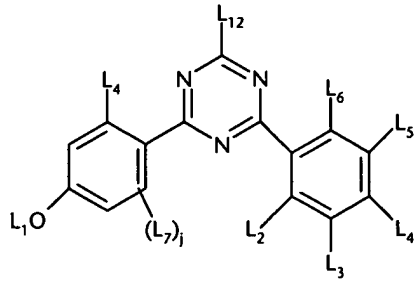
7. (currently amended): A UV absorber composition according to ~~either~~ claim 1 ~~or claim 2~~, wherein, in formula (1),

R_1 and R_2 are C_5-C_{12}alkyl;

R_3 is phenyl; or phenyl-C_1-C_4alkyl; and

R_4 is hydrogen; or C_1-C_5alkyl.

8. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 7~~ claim 1, wherein component (b_1) corresponds to a UV absorber of formula

(6)  wherein

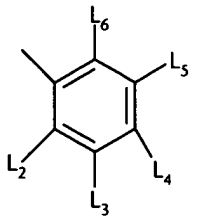
L_1 is C_1-C_{22}alkyl, C_2-C_{22}alkenyl or C_5-C_7cycloalkyl;

L_2 and L_6 are each independently of the other hydrogen, hydroxy, halogen, C_1-C_{22}alkyl or halomethyl;

L_3, L_5 and L_7 are each independently of the others hydrogen, hydroxy, OL_1, halogen, C_1-C_{22}alkyl or halomethyl;

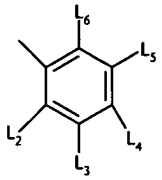
L_4 is hydrogen, hydroxy, -OL_1, halogen, C_1-C_{22}alkyl, phenyl or halomethyl;

L_{12} is C_1-C_{22}alkyl, phenyl-C_1-C_5alkyl, C_5-C_7cycloalkyl, OL_1 or~~, preferably,~~ a group of

formula (6a)  ; and

j is 0, 1, 2 or 3.

9. (original): A UV absorber composition according claim 8, wherein

L_{12} is a radical of formula (6a) 

and

L_2, L_3, L_4, L_5 and L_6 are as defined in claim 8.

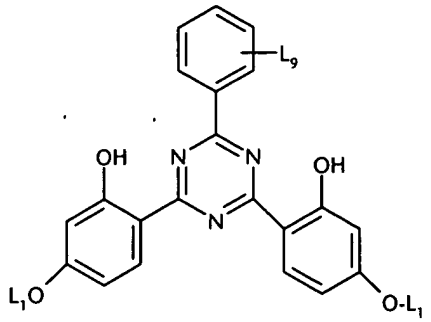
10. (currently amended): A UV absorber composition according to~~ any one of claims 1 to 9~~ claim 8, wherein

L_1 is C_1-C_{22}alkyl; C_2-C_{22}alkenyl; or C_5-C_7cycloalkyl;

L_2, L_3, L_5 and L_7 are hydrogen; and

L_4 and L_6 are as defined in claim 8.

11. (original): A UV absorber composition according claim 8, wherein the hydroxyphenyltriazine compound corresponding to component (b_1) corresponds to formula

(7)  wherein

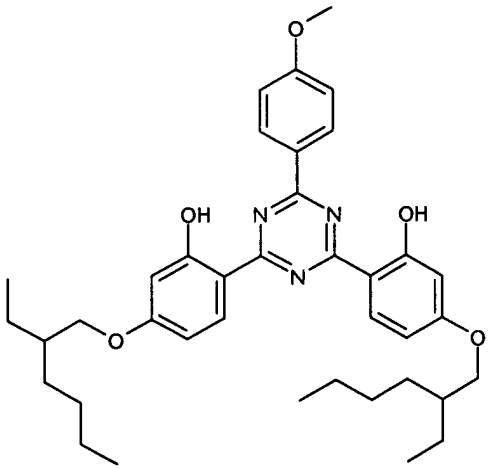
L_1 is C_1-C_{22}alkyl, C_2-C_{22}alkenyl or C_5-C_7cycloalkyl; and

L_9 is C_1-C_5alkyl; or C_1-C_5alkoxy.

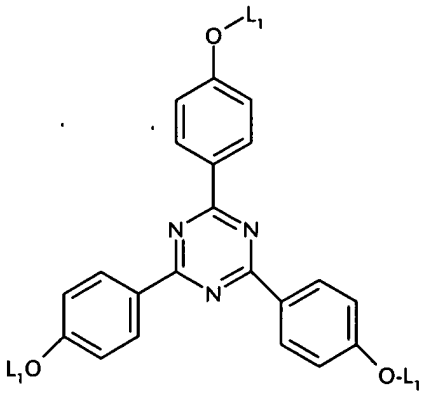
12. (original): A UV absorber composition according to claim 11, wherein

L_1 is C_5-C_{20}alkyl.

13. (original): A UV absorber composition according to claim 8, wherein the hydroxyphenyltriazine compound corresponding to component (b_1) corresponds to formula

(8) 

14. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 8~~ claim 8, wherein the hydroxyphenyltriazine compound corresponding to component (b_1) corresponds to formula

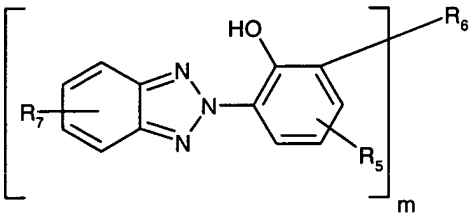
(9)  wherein

L_1 is C_1-C_{22}alkyl.

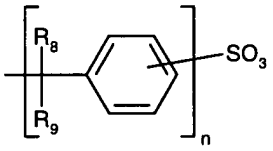
15. (original): A UV absorber composition according to claim 14, wherein

L_1 is methyl.

16. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 7~~ claim 1, wherein component (b_2) is a benzotriazole compound of formula

(10)  wherein

R_5 is C_1-C_{12}alkyl; C_1-C_5alkoxy; C_1-C_5alkoxycarbonyl; C_5-C_7cycloalkyl; C_6-C_{10}aryl; aralkyl; -SO_3M; or a

radical of formula (10a)  ;

R_7 is hydrogen; C_1-C_5alkyl; C_1-C_5alkoxy; halogen, preferably chlorine; or hydroxy;

R_8 and R_9 are each independently of the other hydrogen; or C_1-C_5alkyl;

M is hydrogen or a monovalent counterion;

m is 1 or 2;

n is 0 or 1;

when m = 1,

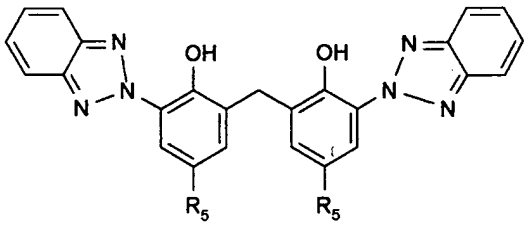
R_6 is hydrogen; unsubstituted or phenyl-substituted C_1-C_{12}alkyl; or C_6-C_{10}aryl;

when m = 2,

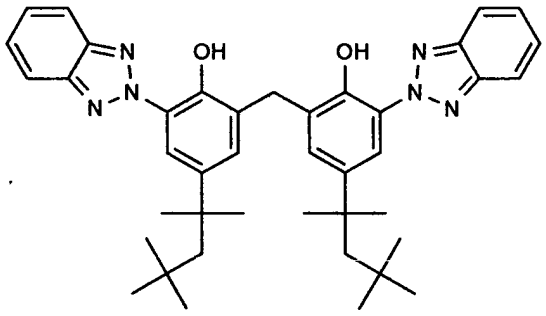
R_6 is a direct bond; or $-(CH_2)_p-$; and

p is from 1 to 3.

17. (original): A UV absorber composition according to claim 16, wherein component (b_2) is a benzotriazole compound of formula

(11)  wherein

R_5 is C_1-C_{12}alkyl.

18. (original): A UV absorber composition according to claim 16, wherein component (b_2) is a benzotriazole compound of formula (12) 

19. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 7~~ claim 1, wherein component (b_3) is 1-(4-tert-butylphenyl)-3-(4-methoxyphenyl)propane-1,3-dione or butylmethoxydibenzoylmethane.

20. (currently amended): A UV absorber composition according to ~~any one of claims 1 to 7~~ claim 1, wherein component (b_4) is a camphor derivative.

21. (original): Use of the compound of formula (1) according to claim 1 as a UV absorber.

22. A method ~~Use~~ according to claim 21, wherein the compound of formula (1) is used as a light-protective agent for human skin and hair.

23. (original): A cosmetic formulation according to claim 1 comprising a compound of formula (1).

24. (original): A cosmetic formulation comprising a UV absorber composition according to claim 1.

25. (currently amended): A cosmetic formulation according to ~~either claim 23 or~~ claim 24, which comprises further substances that absorb UV radiation in the UVB range.

26. (original): A process for the preparation of a compound of formula (1), which comprises reacting the phenylmagnesium bromide compound of formula (1c) in a Grignard reaction with cyanuric chloride (formula (1b)) to form the dichlorotriazine compound of formula (1d), introducing resorcinol groups by Friedel-Crafts acylation of resorcinol (formula (1e)) in the presence of a Lewis acid, and etherifying the free hydroxyl groups in the p- and o-positions of the compound of formula (1f), according to the meaning of the radicals R_1, R_2 and R_3, by alkylation to form the compound of formula (1), in accordance with the following scheme: